

Resource Summary Report

Generated by SPARC SAWG on Sep 17, 2026

JChemPaint

RRID:SCR_000095

Type: Tool

Proper Citation

JChemPaint (RRID:SCR_000095)

Resource Information

URL: <http://jchempaint.github.io/>

Proper Citation: JChemPaint (RRID:SCR_000095)

Description: Chemical 2D structure editor and viewer application/applet based on the Chemistry Development Kit (CDK).

Abbreviations: JCP

Resource Type: software resource

Keywords: applet, mac os x, unix/linux, windows, java

Availability: Free, Available for download, Freely available

Resource Name: JChemPaint

Resource ID: SCR_000095

Alternate IDs: OMICS_04959

Alternate URLs: <https://github.com/JChemPaint/jchempaint>

License: GNU Lesser General Public License

Record Creation Time: 20220129T080159+0000

Record Last Update: 20260912T195503+0000

Ratings and Alerts

No rating or validation information has been found for JChemPaint.

No alerts have been found for JChemPaint.

Data and Source Information

Source: [SciCrunch Registry](#)

Usage and Citation Metrics

We found 1 mentions in open access literature.

Listed below are recent publications. The full list is available at [SPARC SAWG](#) .

Cao M, et al. (2015) Predicting retention time in hydrophilic interaction liquid chromatography mass spectrometry and its use for peak annotation in metabolomics. Metabolomics : Official journal of the Metabolomic Society, 11(3), 696.